

Exciton-exciton annihilation in MoSe₂ monolayersNardeep Kumar,¹ Qiannan Cui,¹ Frank Ceballos,¹ Dawei He,² Yongsheng Wang,^{2,*} and Hui Zhao^{1,†}¹*Department of Physics and Astronomy, The University of Kansas, Lawrence, Kansas 66045, USA*²*Key Laboratory of Luminescence and Optical Information, Ministry of Education, Institute of Optoelectronic Technology, Beijing Jiaotong University, Beijing 100044, China*

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We investigate the excitonic dynamics in MoSe₂ monolayer and bulk samples by femtosecond transient absorption. Excitons are resonantly injected by a 750-nm and 100-fs laser pulse, and are detected by measuring a differential reflection of a probe pulse tuned in the range 790–820 nm. We observe a strong density-dependent initial decay of the exciton population in monolayers, which can be well described by the exciton-exciton annihilation. Such a feature is not observed in a bulk sample under comparable conditions. We also observe the saturated absorption induced by excitons in both monolayers and the bulk in the differential reflection measurements, which indicates their potential applications as saturable absorbers.

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I. INTRODUCTION

Layered materials in which atomic sheets are stacked together by the weak van der Waals force can be used to fabricate two-dimensional (2D) systems, which can have exotic properties that are very different from their bulk counterparts. They represent a new approach to develop nanomaterials. Since 2004, most efforts have been focused on graphene [1–4]. More recently, however, other layered materials have drawn considerable attentions [5–7]. For example, atomically thin semiconducting transition metal dichalcogenides, MX_2 ($M = \text{Mo}, \text{W}; X = \text{S}, \text{Se}, \text{Te}$), have shown several interesting properties, such as transition to a direct band gap in monolayers [8–13], valley-selective optical coupling [14–20], and large nonlinear optical responses [21–24]. Various applications of monolayer MX_2 have also been developed, including field-effect transistors [25–28], integrated circuits [29,30], phototransistors [31], chemical sensors [32], and light-emitting diodes [33].

In these atomically thin 2D structures, the exciton binding energies [34–37] are much larger than semiconductor quantum wells—the previously extensively studied quasi-2D systems. Hence, they provide a new platform to study excitons in confined systems. Since the optical properties of these systems are dominated by excitons even at room temperature, for various applications, it is important to understand their excitonic dynamics. Here we report an ultrafast optical study of the excitonic dynamics in MoSe₂ monolayer and bulk samples.

So far, most studies on MX_2 have focused on one member of this family, MoS₂. Other members have similar lattice structures as MoS₂, but possess different properties, such as the sizes of the band gap and the strengths of the spin-orbital coupling [6]. Hence, they can potentially be used to complement MoS₂ in some applications. More importantly, it is possible to use various types of atomic layers as building blocks to assemble multilayer structures and even three-dimensional crystals to achieve desired properties [38]. Therefore, understanding the basic properties of these building blocks is essential. Recently, strong exciton [39] and trion [36]

photoluminescence has been observed in monolayers of MoSe₂ in time-integrated measurements. The high temporal resolution of our transient absorption measurements allows us to directly study the dynamics of excitons in MoSe₂ monolayers. We observe efficient exciton-exciton annihilation at high exciton densities, which reveals the strong interaction between excitons in this strongly confined system. Similar measurements performed on a bulk sample indicate that this process is absent in bulk.

II. EXPERIMENTAL SETUP AND SAMPLES

MoSe₂ monolayer samples are fabricated by mechanical exfoliation with an adhesive tape from bulk crystals (2D semiconductors). By depositing flakes of MoSe₂ on silicon substrates with either a 90-nm or a 280-nm SiO₂ layer, we can identify large flakes of MoSe₂ monolayers with an optical microscope, by utilizing optical contrasts enhanced by the multilayer substrate [40,41]. Photoluminescence and Raman spectroscopy are also performed to confirm the thickness of the flakes studied. All the measurements were performed in ambient condition and no signs of sample degradation were observed during the entire study.

The experimental setup for the transient absorption measurements is shown in Fig. 1. An 80-MHz mode-locked Ti:sapphire laser (Ti:Sa) is used to generate 100-fs pulses with a central wavelength in the range 790–820 nm. The majority of this beam is used to pump an optical parametric oscillator (OPO), which has a signal output of 1500 nm. To obtain the pump pulse for the measurement, a beta barium borate (BBO) crystal is used to generate the second harmonic of this beam, with a wavelength of 750 nm. Tuned to the high-energy edge of the lowest energy exciton resonance, the pump pulse injects excitons by resonant excitation. The injected excitons are probed by a 100-fs pulse with a different wavelength in the low-energy side of the resonance. It is obtained directly from the Ti:sapphire laser. The reflected probe is directed to a photodetector of a balanced detector, whose output is measured by a lock-in amplifier. A portion of the probe is taken before entering the objective lens and is sent to the other detector for balanced detection, which improves the signal-to-noise ratio of the system [42]. By using a microscope objective lens, we tightly focus both the pump and the probe pulses to spot

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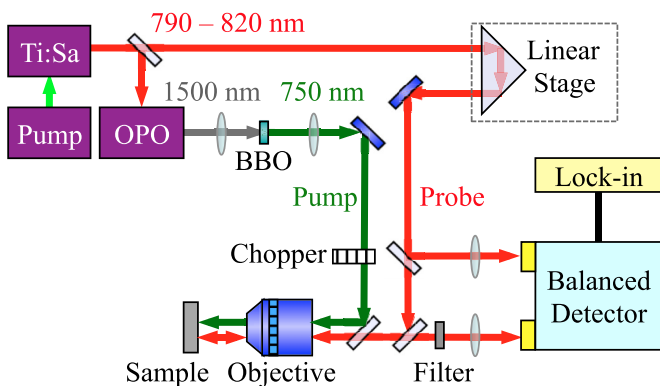


FIG. 1. (Color online) Schematics of the transient absorption setup.

sizes of about $1 \mu\text{m}$, which is several times smaller than the dimensions of the flakes studied. The pump and the probe spots are overlapped, and are located near the center of the flakes in all the measurements.

III. TRANSIENT ABSORPTION TO PROBE EXCITONS

Figure 2(a) shows a differential reflection signal of the 810-nm probe pulse as a function of the probe delay (defined as the time delay of the probe pulse with respect to the pump).

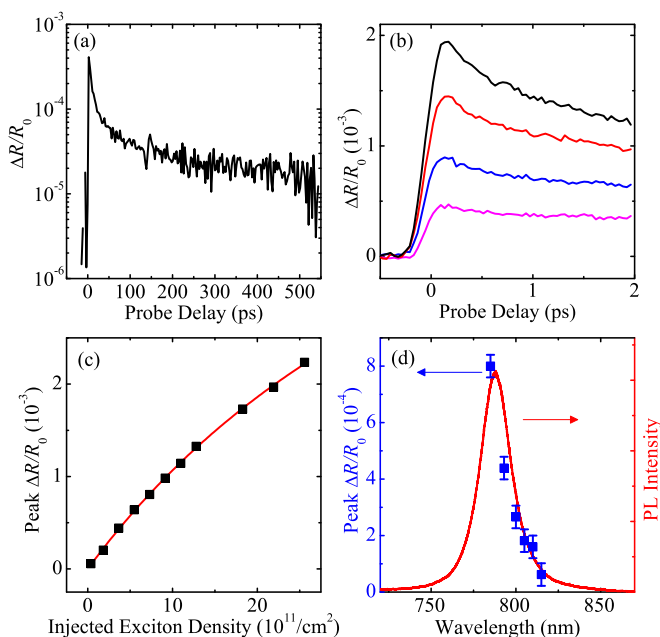


FIG. 2. (Color online) (a) Differential reflection of a MoSe_2 monolayer measured with a probe wavelength of 810 nm and a pump wavelength of 750 nm. The energy fluence of the pump pulse at the center of the pump spot is $8 \mu\text{J}/\text{cm}^2$. (b) Differential reflection signal near zero probe delays with pump fluences of (from bottom to top) 10, 20, 40, and $55 \mu\text{J}/\text{cm}^2$, respectively. (c) Peak differential reflection signal as a function of the injected exciton density. The solid line is a fit. (d) Peak differential reflection signal as a function of the probe wavelength (squares, left axis). The solid line is a photoluminescence (PL) spectrum of the sample.

The differential reflection is defined as the relative change of the reflection of the probe, $\Delta R/R_0 = (R - R_0)/R_0$, where R and R_0 are the reflection of the probe with and without the presence of the pump pulse, respectively. We find that the differential reflection signal decays quickly in the first 50 ps and then slowly over several hundred ps. Since the differential reflection is related to the exciton density, its decay reflects the excitonic dynamics. We note that the peak signal here is below 0.1%. Hence, the pump does not significantly change the absorption coefficient of the sample.

In order to establish a precise relation between the differential reflection and the exciton density, we repeat the measurement with different pump fluences. Figure 2(b) shows the measured differential reflection near zero probe delay with four different pump fluences. In each case, the rising time of the signal is limited by the instrument response. Hence, the excitons injected by the pump pulse instantaneously change the probe reflection. From the pump fluence, we can estimate the injected exciton density by using an absorption coefficient of $2 \times 10^5/\text{cm}$ [43] and assuming that every pump photon absorbed excites one exciton. We note that the saturation of the pump absorption can be safely neglected, since the pump only changes the probe absorption by less than 0.1%. Since the exciton lifetime, indicated by the decay of the signal, is much longer than the rising time, we can ignore the decay of the exciton density during the pump pulse and assume that the exciton density at the peak time equals the injected density. This procedure allows us to relate the differential reflection signal to the exciton density, as we plot in Fig. 2(c). We find that the relation can be accurately described by a saturable absorption model [44],

$$\frac{\Delta R}{R_0} \propto \frac{N}{N + N_s}, \quad (1)$$

where N and N_s are the exciton density and the saturation density, respectively. The solid line in Fig. 2(c) indicates a fit to the data, with $N_s = (5.8 \pm 0.5) \times 10^{12}/\text{cm}^2$. Such a saturation density corresponds to an average exciton distance of about 4 nm. The exciton Bohr radius a_B in monolayer MX_2 has been estimated to be about 1 to 2 nm [17,36], suggesting a saturation density $(\pi a_B^2)^{-1}$ on the order of $1 \times 10^{13}/\text{cm}^2$. The saturation density deduced here is reasonably consistent with these calculations.

Since the monolayer sample is attached to a multilayer substrate of Si/SiO_2 , the reflection of the probe is determined by the complex index of refraction of each layer. Hence, the differential reflection is related to, in a rather complex way, the fractional changes of the absorption coefficient and the real index of refraction of the monolayer MoSe_2 induced by the pump. However, when the fractional changes are much smaller than 1, the differential reflection is approximately proportional to both fractional changes, as we have shown previously [45].

To further study the mechanism of the saturable absorption, we repeat the measurement at different probe wavelengths, with a fixed pump wavelength of 750 nm. We observed the same dynamics and the saturation behavior shown in Figs. 2(a)–2(c). The peak $\Delta R/R_0$ with a pump fluence of $4 \mu\text{J}/\text{cm}^2$ is plotted as the squares in Fig. 2(d) (left axis). Clearly, the spectrum of $\Delta R/R_0$ coincides with the photoluminescence (PL) spectrum [solid line in Fig. 2(d)],

which is measured with a 633-nm continuous-wave laser excitation. It has been shown that in monolayer MoSe₂, the PL spectrum is consistent with the absorption spectrum [36]. Hence, this result indicates that the pump-injected excitons reduce the exciton transition strength. The transient absorption is not dominated by the broadening nor the shifting of the resonance, since in either case the spectrum would have been significantly different from the PL spectrum [46]. This is quite different from monolayers of MoS₂, in which previous studies have shown rather complex spectra of transient absorption [47,48]. We note that the probe wavelength range in this measurement is limited by the instruments: Tuning the Ti:Sa to wavelengths shorter than 780 nm would result in inefficient pumping of the OPO and a poor signal-to-noise ratio due to the partial overlap of the spectra of the pump and probe pulses.

The observed excitonic absorption saturation and the unusually large exciton binding energy indicate potential applications of MoSe₂ monolayers as saturable absorbers for various nonlinear photonic devices [49]. Here, however, our purpose is to use the absorption saturation to study excitonic dynamics. In principle, the solid line in Fig. 2(c) allows us to precisely convert the measured $\Delta R/R_0$ to N . In this study, however, most measurements are performed with $N \ll N_s$, so that the $\Delta R/R_0$ is approximately proportional to N .

IV. EXCITON-EXCITON ANNIHILATION

We study exciton dynamics at different injection levels. The left column of Fig. 3 shows that the decay of the exciton density depends strongly on the initially injected density. When increasing the injected density, a fast decay component develops. Such a density-dependent decay is not expected from a noninteracting exciton system, thus indicating strong exciton-exciton interactions.

It is well known that in strongly confined systems, such as organic crystals, excitation of nearby molecules can result in annihilation of excitons due to their strong interactions [50–52]. The exciton-exciton annihilation has also been observed in one-dimensional structures, such as semiconducting carbon nanotubes [53,54]. However, its observation in quasi-2D systems, such as semiconductor quantum wells, is rare. Since MX_2 monolayers are atomically thin, strong exciton-exciton coupling can be expected. Including exciton-exciton annihilation, the rate equation of the exciton density can be written as

$$\frac{dN}{dt} = -\frac{1}{\tau}N - \frac{1}{2}\gamma N^2, \quad (2)$$

where τ and γ are the exciton lifetime and exciton-exciton annihilation rate, respectively [54]. One could attempt to compare the solution of this equation with the data. However, for pedagogical considerations, here we discuss separately contributions of the two mechanisms. This is possible because the exciton-exciton annihilation is only significant in early times when the densities are high, while the single-particle process dominates decays on longer time scales with lower densities. In fact, we find that the data after 150 ps can be satisfactorily fit by a single exponential function, as indicated by the red lines in Fig. 3 (left column).

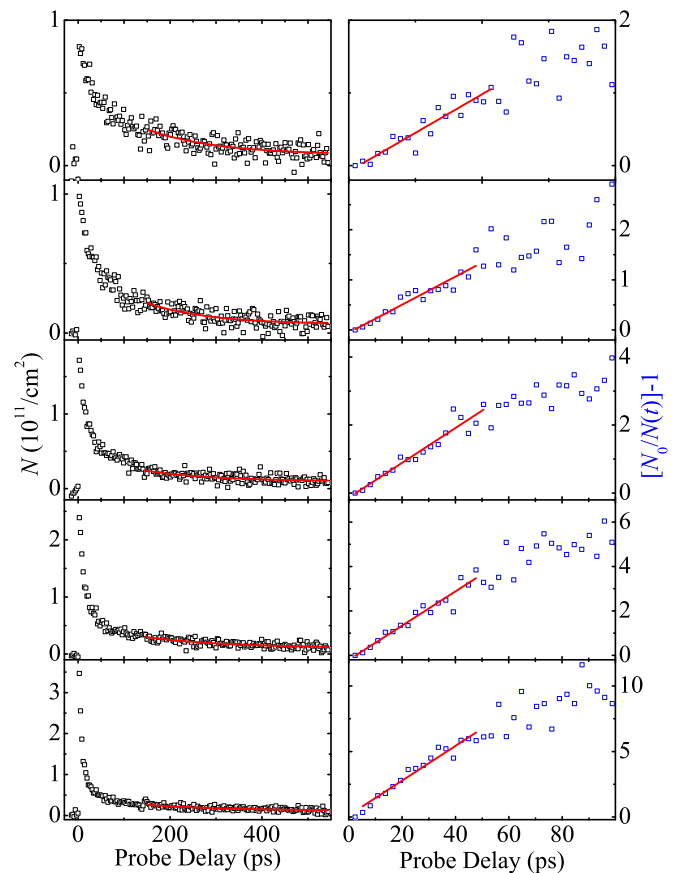


FIG. 3. (Color online) Left column: Exciton density, deduced from the measured differential reflection signal, as a function of the probe delay with different injected densities. The red lines are single exponential fits to the data after 150 ps. Right column: the quantity $N_0/N(t) - 1$ calculated from data in the left column as a function of the probe delay. The red lines are linear fits.

Without the first term on the right-hand side, the solution to Eq. (2) is simply

$$\frac{N_0}{N(t)} - 1 = \gamma N_0 t, \quad (3)$$

where N_0 is the initially injected exciton density at $t = 0$. In view of this, we calculate $N_0/N(t) - 1$ from the data shown in each panel in the left column of Fig. 3, and plot it as a function of t in the right column. In the first 50 ps, the data are consistent with Eq. (3), as indicated by the solid lines. We attribute the deviation from linear after 50 ps to the contribution of the first term in Eq. (2). From linear fits, shown as the solid lines in Fig. 3 (right column), we deduce the slopes γN_0 . We find that the slope is indeed proportional to N_0 , as shown in Fig. 4. From a linear fit, shown as the solid line in Fig. 4, we obtain an exciton-exciton annihilation rate of $\gamma = 0.33 \pm 0.06$ cm²/s. We repeat the measurement on two other monolayer samples, and obtained similar results, as summarized in the two insets of Fig. 4.

The observation of the exciton-exciton annihilation illustrates the strong interaction between excitons in monolayers of MoSe₂. In a recent study, strong interexciton coupling in monolayers of MoS₂ was revealed, and a fast initial decay

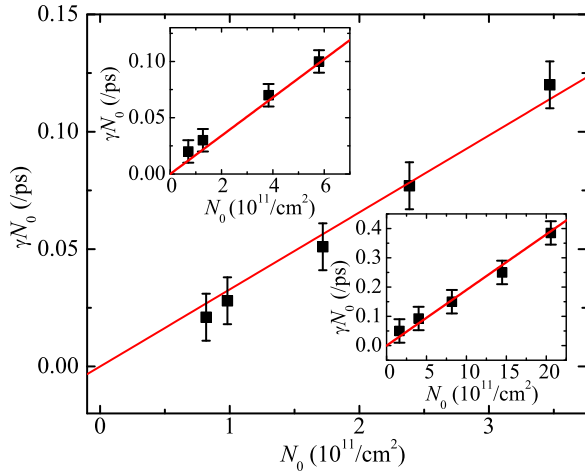


FIG. 4. (Color online) Rate of increase of the quantity $N_0/N(t) - 1$, deduced from linear fits shown in the right column of Fig. 3, as a function of the injected exciton density. The solid line indicates a linear fit. The two insets show similar results from two other samples.

of the transient absorption signal was observed; however, no density-dependent behavior reported here was observed [48].

V. EXCITON DYNAMICS IN A BULK SAMPLE

The observation of the exciton-exciton annihilation in monolayer MoSe₂ stimulated us to perform a comparison study on bulk MoSe₂. The bulk sample studied is on the same substrate as the monolayer samples, fabricated from the same crystal. The measurement is performed with the same transient absorption setup. Excitons are injected by the 750-nm pump pulse, and probed with the 810-nm pulse. According to the absorption coefficient at the pump wavelength of $2 \times 10^5/\text{cm}$ [43], the absorption depth of the pump pulse is about 50 nm. Figure 5(a) shows the differential reflection signal measured in a short time range of a few ps, with different pump fluences. As we observed in monolayers, the differential reflection signal rises to a peak quickly, limited by the time resolution. This indicates the instantaneous saturation effect of the resonantly injected excitons. From these data, we obtain the peak differential reflection signal as a function of the injected exciton density, as shown in Fig. 5(b). Here, the bulk exciton density represents its peak value at the center of the pump spot and at the sample surface. It is deduced from the pump fluence and the absorption coefficient. Similar to the monolayers, the differential reflection signal can be well described by the saturable absorption model [Eq. (1)], as indicated as the solid line. We obtain a saturation density of $(2.2 \pm 0.3) \times 10^{19}/\text{cm}^3$.

Next, we measure the differential reflection signal over a longer time range of about 1 ns with various pump fluences, and deduce the exciton density by using the solid line shown in Fig. 5(b). The results are plotted in Fig. 5(c). No signature of exciton-exciton annihilation is observed, and all the data can be satisfactorily fit by single exponential functions with time constants in the range 300–400 ps, as indicated as the solid lines in Fig. 5(c). We note that the highest density of $1.2 \times 10^{19}/\text{cm}^3$ used in this measurement corresponds to an areal

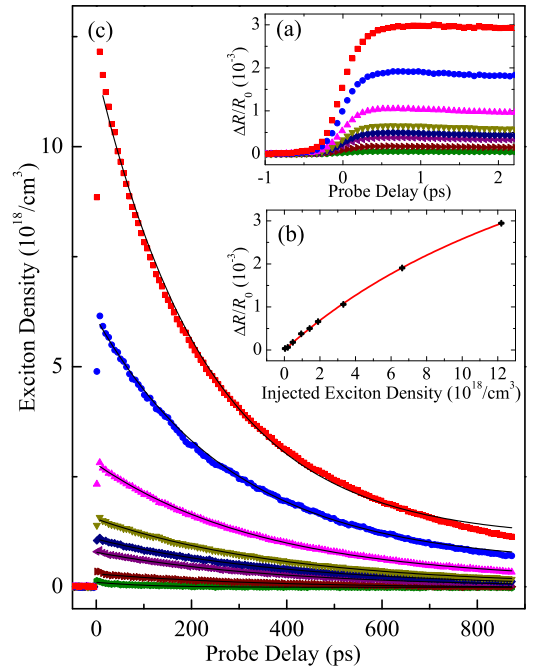


FIG. 5. (Color online) Exciton dynamics in bulk MoSe₂. (a) Differential reflection signal with the probe delays in a short time range near zero delay measured from a bulk MoSe₂ sample. The pump fluences are (from top to bottom) 21.8, 11.8, 5.9, 3.3, 2.5, 1.7, 0.8, and 0.3 $\mu\text{J}/\text{cm}^2$, respectively. (b) Peak differential reflection signal as a function of the injected peak exciton density. The red line is a fit to the data using Eq. (1). (c) Decay of the exciton density at different initial injection levels. The solid lines are exponential fits to the data.

density of $8.4 \times 10^{11}/\text{cm}^2$ in the first atomic layer (0.7-nm thick), which is larger than areal densities used in the monolayer measurement. Finally, we attribute the longer decay time of the exciton density in the bulk sample to longer exciton lifetimes in bulk, probably due to the indirect band gap and less surface contributions to the exciton recombination.

VI. CONCLUSIONS

In summary, we studied excitonic dynamics in MoSe₂ by femtosecond transient absorption and observed exciton-exciton annihilation in monolayers, which is absent in bulk under similar conditions. This process reveals strong coupling between excitons in this strongly confined two-dimensional system. We also found that the exciton lifetime is longer in bulk than monolayers. Furthermore, we observed saturation absorption in both monolayer and bulk samples, and deduced saturation densities. This observation, combined with the unusually large exciton binding energies, suggest potential uses of MoSe₂ monolayers and bulk as saturable absorbers.

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